IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| In Re Application of: |) |
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| Song et al. |) Group Art Unit: 1752 |
| Serial No.:10/720,966 |) Examiner: John S. Y. Chu |
| Filed: November 24, 2003 |) Confirmation No.: 5221 |
| For: PHOTORESIST COMPOSITION AND METHOD PATTERN FORMING USING THE SAME |) TKHR Docket: 250913-1030) Top-Team: 0424-8857US |

RESPONSE TO OFFICE ACTION

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed May 31, 2006, has been carefully considered. In response thereto, please consider the following remarks.